Ref #	Hits	Search Query	DBs	Default Operator	Plurais	Time Stamp
L1	80767	("257"/\$.ccls. "438"/\$.ccls. "427"/\$.ccls.) and (tungsten w.)	USPAT	OR	OFF	2005/02/16 09:34
L2	869	1 and (si silicon polysilicon semiconductor) near5 ("over" "on") near3 (tungsten w)	USPAT	OR	OFF	2005/02/16 09:41
L3	627	2 not ((sin si!x si!>"sub.x" sio2 "sio?sub.2" "si?sub.3" adj "n?sub. 4" silicon adj (nitride dioxide oxide)) near5 ("over" "on") near3 (tungsten w))	USPAT	OR	OFF	2005/02/16 09:41
L4	624	3 and (si silicon polysilicon semiconductor) near7 (tungsten w)	USPAT	OR	OFF	2005/02/16 09:44
L5	338	4 and (tungsten w) same gate	USPAT	OR	OFF	2005/02/16 09:42
L6	289	5 and (si silicon polysilicon semiconductor) adj7 (tungsten w)	USPAT	OR	OFF	2005/02/16 09:45
S3	8	(("4770948") or ("5341016") or ("5594569") or ("5643826") or ("5738948") or ("5923962") or ("6285042") or ("6335541")).PN.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/02/07 11:48
S4		("6614083").PN.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/02/07 11:48
S5	9	S3 S4	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/02/07 12:18
S6	1	"05263226"	JPO	OR	OFF	2005/02/07 11:50
S7	1	"07130652" or "08153722"	JPO	OR	OFF	2005/02/07 11:52
S8	0	"07130652"	JPO ,	OR	OFF	2005/02/07 11:52
S9	2	S5 and purity same (tungsten w)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/02/07 13:22
S10	1	S5 and (sodium na alkali) same (tungsten w)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/02/07 12:01
S11	82164	("257"/\$.ccls. "438"/\$.ccls. "427"/\$.ccls.) and (tungsten w refractory adj metal\$1)	USPAT	OR	OFF	2005/02/16 09:32
S12	732	S11 and (tungsten w refractory adj metal\$1) same purity	USPAT	OR	OFF	2005/02/10 14:28
S13	69	S12 and (tungsten w refractory adj metal\$1) same (sodium na alkali)	USPAT	OR	OFF	2005/02/07 13:22
S14	4	(("5913100") or ("6088070") or ("6303483") or ("6313481")).PN.	US-PGPUB; USPAT; EPO; JPO	OR 、	OFF	2005/02/07 13:21

S15	0	S14 and purity same (tungsten w)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/02/07 13:22
S16	0	S15 and (tungsten w refractory adj metal\$1) same (sodium na alkali)	USPAT	OR	OFF	2005/02/07 13:22
S17	82458	("257"/\$.ccls. "438"/\$.ccls. "427"/\$.ccls.) and (tungsten w refractory adj metal)	USPAT	OR	ON	2005/02/10 14:34
S18	2027	S17 and (tungsten w refractory adj metal\$1) same (stress ity)	USPAT	OR	OFF	2005/02/10 14:39
S19	5079	S17 and (tungsten w refractory adj metal\$1) same (physical adj vapor sputter\$3) and (stress resistivity)	USPAT	OR	ON	2005/02/10 17:24
S20	2275	S19 and (tungsten w refractory adj metal\$1) same (physical adj vapor sputter\$3) same (wire wiring interconnect\$3 lead electrode runner)	USPAT	OR	ON	2005/02/10 14:49
S21	429	S20 and (tungsten w refractory adj metal\$1) same (physical adj vapor sputter\$3) same (wire wiring interconnect\$3 lead electrode runner) same (stress resistivity)	USPAT	OR	ON	2005/02/10 14:56
S22	332	S21 and (tungsten w refractory adj metal\$1) same (pattern\$3 etch\$3)	USPAT	OR	ON	2005/02/10 14:55
S23	309	S22 and (tungsten w) same (pattern\$3 etch\$3)	USPAT	OR	ON	2005/02/10 14:56
S25	82275	("257"/\$.ccls. "438"/\$.ccls. "427"/\$.ccls.) and (tungsten w refractory adj metal\$1)	USPAT	OR	OFF	2005/02/10 17:26
S26	1809	S25 and (tungsten w) same sputter\$3 same (ar argon)	USPAT	OR	ON.	2005/02/10 17:29
S27	83	S26 and (tungsten w) same sputter\$3 same (purity impurity) and stress	USPAT	OR	ON	2005/02/10 17:30
S28	83	S27 and (tungsten w) same sputter\$3 same (purity impurity)	USPAT	OR	ON	2005/02/10 17:30